

**WHAT IS CLAIMED IS:**

1. A reflective-transmissive type liquid crystal display device, comprising:  
a first substrate, including:

5 a thin film transistor disposed on a first transparent substrate;  
an organic insulation layer disposed on the first transparent substrate to  
insulate the thin film transistor, the organic insulation layer having a contact hole  
for exposing an output terminal of the thin film transistor;

10 a pixel electrode having a transparent electrode connected to the output  
terminal of the thin film transistor through the contact hole disposed on the  
organic insulation layer, and a reflective electrode disposed on a first region of  
the transparent electrode, a second region of the transparent electrode being  
exposed without being covered by the reflective electrode; and

15 an orientation film coated on an upper surface of the pixel electrode and  
having an orientation groove rubbed in a first direction, the orientation groove  
preventing impurity from being stacked at a boundary between the first and  
second regions of the transparent electrode;

a second substrate, including:

20 a color filter disposed on a second transparent substrate in opposition to  
the pixel electrode; and

a common electrode disposed on an upper surface of the color filter and  
facing the pixel electrode; and

a liquid crystal interposed between the first and second substrates.

25 2. The reflective-transmissive type liquid crystal display device as claimed in

claim 1, wherein the boundary of the first and second regions has a linear shape in a layout of the pixel electrode.

3. The reflective-transmissive type liquid crystal display device as claimed in  
5 claim 2, wherein the first direction is parallel to the boundary.

4. The reflective-transmissive type liquid crystal display device as claimed in  
claim 2, wherein the reflective electrode includes a sidewall making contact with the  
boundary of the first and second regions, and the sidewall is inclined to prevent the  
10 impurity from being stacked at the boundary.

5. The reflective-transmissive type liquid crystal display device as claimed in  
claim 1, wherein the second region exposes two edges of the first region of the transparent  
electrode, and the two edges are connected to each other.

15 6. The reflective-transmissive type liquid crystal display device as claimed in  
claim 5, wherein the reflective electrode includes a sidewall making contact with the  
boundary of the first and second regions, and the sidewall is inclined to prevent the  
impurity from being stacked at the boundary.

20 7. The reflective-transmissive type liquid crystal display device as claimed in  
claim 5, wherein the boundary between the first and second regions, and the first region  
each include a L-shaped configuration.

25 8. The reflective-transmissive type liquid crystal display device as claimed in

claim 1, wherein the second region partially exposes one edge of the transparent electrode.

9. The reflective-transmissive type liquid crystal display device as claimed in claim 8, wherein the reflective electrode includes a sidewall making contact with the boundary of the first and second regions, and the sidewall is inclined to prevent the impurity from being stacked at the boundary.

10. The reflective-transmissive type liquid crystal display device as claimed in claim 8, wherein the boundary between the first and second regions, and the first region each include a U-shaped configuration.

11. The reflective-transmissive type liquid crystal display device as claimed in claim 1, wherein the second region is formed on an inside of the first region, and wherein the reflective electrode includes a sidewall adjacent to the boundary of the first and second regions, the sidewall being inclined to prevent the impurity from being stacked at the boundary.

12. The reflective-transmissive type liquid crystal display device as claimed in claim 11, wherein the transparent electrode includes a plurality of the second regions, and wherein the second regions include a circular shape or a rectangular shape.

13. The reflective-transmissive type liquid crystal display device as claimed in claim 11, wherein the color filter comprises a first tone at the first region corresponding to the reflective electrode and a second tone at the second region of the transparent electrode being exposed without being covered by the reflective electrode, which is

different from the first tone.

14. A method for fabricating a reflective-transmissive type liquid crystal display device, the method comprising:

5 forming a thin film transistor on a first transparent substrate;

depositing an organic insulation layer on the first transparent substrate to insulate the thin film transistor, the organic insulation layer having a contact hole for exposing an output terminal of the thin film transistor;

10 forming a pixel electrode on the organic insulation layer, the pixel electrode having a transparent electrode connected to the output terminal of the thin film transistor through the contact hole and a reflective electrode formed on a first region of the transparent electrode, a second region of the transparent electrode being exposed without covering by the reflective electrode;

coating an orientation film on an upper surface of the pixel electrode

15 rubbing the orientation film in a first direction to form an orientation groove on the orientation film, the orientation groove preventing impurity from being stacked at a boundary between the first and second regions of the transparent electrode;

forming a color filter on a second transparent substrate in opposition to the pixel electrode;

20 forming a common electrode on an upper surface of the color filter, the common electrode facing the pixel electrode; and

interposing a liquid crystal between the common electrode and the pixel electrode on which the orientation film and the orientation groove are formed.

25 15. The method as claimed in claim 14, wherein forming a pixel electrode

comprises:

forming the transparent electrode on the first transparent substrate on which the thin film transistor and the organic insulation layer are formed;

forming a metal thin film on an upper surface of the transparent electrode; and

5        patterning the metal thin film such that the reflective electrode is formed on the first area of the transparent electrode and the boundary between the first and second regions has a linear shape in a layout of the pixel electrode.

16.    The method as claimed in claim 15, wherein patterning the metal thin film  
10 includes forming a sidewall of the reflective electrode at the first region adjacent to the boundary, the sidewall slanting to prevent the impurity from being stacked at the sidewall of the reflective electrode.

17.    The method as claimed in claim 14, wherein forming a pixel electrode  
15 comprises:

forming the transparent electrode on the first transparent substrate on which the thin film transistor and the organic insulation layer are formed;

forming a metal thin film on an upper surface of the transparent electrode; and

18        patterning the metal thin film such that the reflective electrode is formed on the first  
20 region of the transparent electrode and the second region exposes two edges of the transparent electrode, the two edges being connected to each other.

18.    The method as claimed in claim 17, wherein patterning the metal thin film  
includes forming a sidewall of the reflective electrode at the first region adjacent to the  
25 boundary, the sidewall slanting so as to prevent the impurity from being stacked at the

sidewall of the reflective electrode.

19. The method as claimed in claim 14, wherein forming a pixel electrode comprises:

5 forming the transparent electrode on the first transparent substrate on which the thin film transistor and the organic insulation layer are formed;

forming a metal thin film on an upper surface of the transparent electrode; and

patterning the metal thin film such that the reflective electrode is formed on the first region of the transparent electrode and the second region exposes one edge of the  
10 transparent electrode.

20. The method as claimed in claim 19, wherein patterning the metal thin film includes forming a sidewall of the reflective electrode at the first region adjacent to the boundary, the sidewall slanting so as to prevent the impurity from being stacked at the  
15 sidewall of the reflective electrode.

21. The method as claimed in claim 14, wherein forming a pixel electrode comprises:

forming the transparent electrode on the first transparent substrate such that the  
20 second region is formed on an inside of the first region;

forming a metal thin film on an upper surface of the transparent electrode; and

patterning the metal thin film such that the reflective electrode is formed on the first region of the transparent electrode, and a sidewall of the reflective electrode is slantingly formed at the first region adjacent to the boundary so as to prevent the impurity  
25 from being stacked at the sidewall of the reflective electrode.

22. The method as claimed in claim 21, wherein the transparent electrode includes a plurality of the second regions.

5 23. The method as claimed in claim 21, wherein the second regions include a circular shape or a rectangular shape.

24. The method as claimed in claim 14, wherein the first direction is formed from the reflective electrode to the transparent electrode.

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